## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Wunnicke, et al. Docket No.: INF 2004 SP 00138 US

Serial No.: 10/781,920 Art Unit: 1756

Filed: February 20, 2004 Examiner: Brittany L. Raymond

For: Method for Fabricating a Resist Mask for Patterning Semiconductor

Substrates

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## **AMENDMENT**

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed August 1, 2007. Please amend the above-referenced application as follows.

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